## He desorption from W/He co-deposit layers by TDS

L. Laguardia<sup>a</sup>, M. Pedroni<sup>a</sup>, E. Vassallo<sup>a</sup>, M. De Angeli<sup>a</sup>, F.Ghezzi<sup>a</sup>, M. Iafrati<sup>b</sup>, M. Alonzo<sup>b</sup>, S. Almaviva<sup>b</sup>, G. Gervasini<sup>a</sup>, A. Uccello<sup>a</sup>, A. Cremona<sup>a</sup>

<sup>a</sup> Institute for Plasma Science and Technology (ISTP-CNR), Via R. Cozzi 53, I-20125 Milan, Italy
<sup>b</sup> ENEA, Department of Fusion and Nuclear Safety Technology, 00044 Frascati, Rome, Italy

In this study we present results of the He released from W/He codeposit layers obtained by thermal desorption experiments.

Sample: 500 nm of W/He were co-deposited on W substrates 12.5 x 12.5 x 5 mm<sup>3</sup>, by means of Magnetron Sputtering of a W electrode in an Ar:He gas mixture.

He retention measured by Thermal Desorption experiments performed with two different heating systems (inductive and resistive).

## **TDS results**

The samples were heated up to 1000°C at a ramp rate of 50°C /min.

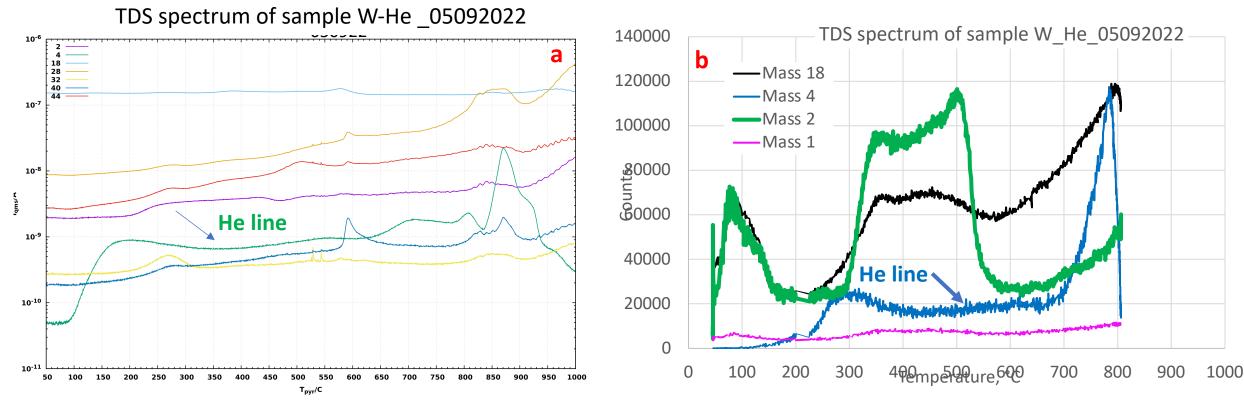


Figure a. TDS experiment with inductive heating system, using pyrometer for temperature measure.

Figure b. TDS experiment with resistive heating system , using thermocouple for temperature measure.

In the above figures the He ion current is reported as a function of the temperature. In both types of experiments, the sample exhibits a broad desorption peak at about 250°C and another one at at 870°C

## **TDS spectra of the samples after different times**

